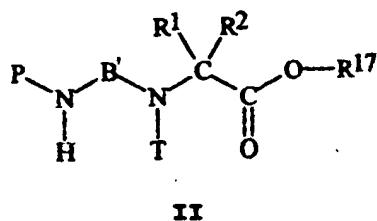
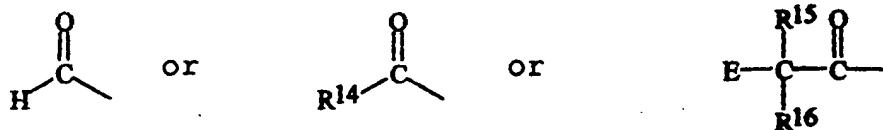


**APPENDIX (with claim markings):**

6. (Amended) A compound of the general formula II



in which T is hydrogen or a group of the formula



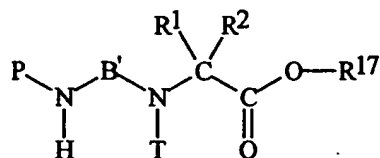
the residue R<sup>17</sup> is hydrogen or allyl, benzyl, ethyl, methyl, 2,2,2-trichloro-tert-butyl, 2,2,2-trichloroethyl, α-chloro-(trifluoromethyl)benzyl, 2-(p-toluenesulfonyl)ethyl, diphenyl-methyl, 2-(trimethylsilyl)ethyl, methoxymethyl, (2-trimethyl-silyl)ethoxymethyl, benzyloxymethyl, or (2-methoxy) ethyloxymethyl,

the residue P is hydrogen or an amine protecting group,

the residue R<sup>14</sup> is a group of the formula CH<sub>n</sub>X<sub>3-n</sub> (n = 0 to 3, X = F, Cl, Br, I), a phenyl group, or a p-methoxyphenyl group, and

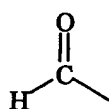
B', E, the residues R<sup>1</sup> [und] and R<sup>2</sup>, and R<sup>15</sup> [und] and R<sup>16</sup> have the meanings stated in [claims 1 to 5] claim 1.

9. (Twice Amended) A process for the production of a compound as defined in claim 1, wherein compounds of the general formula II

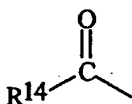


II

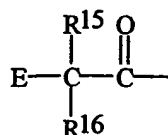
in which T is hydrogen or a group of the formula



or



or



the residue R<sup>17</sup> is hydrogen or allyl, benzyl, ethyl, methyl, 2,2,2-trichloro-tert-butyl, 2,2,2-trichloroethyl, α-chloro-(trifluoromethyl)benzyl, 2-(p-toluenesulfonyl)ethyl, diphenyl-methyl, 2-(trimethylsilyl)ethyl, methoxymethyl, (2-trimethyl-silyl)ethoxymethyl, benzyloxymethyl, or (2-methoxy)ethyloxymethyl,

the residue P is hydrogen or an amine protecting group,

the residue R<sup>14</sup> is a group of the formula CH<sub>n</sub>X<sub>3-n</sub> (n = 0 to 3, X = F, Cl, Br, I), a phenyl group, or a p-methoxyphenyl group, and

B', E, the residue R<sup>1</sup> and R<sup>2</sup>, and R<sup>15</sup> and R<sup>16</sup> have the meanings stated in claim 1 [wherein compounds as defined in claim 6] are converted in known matter.